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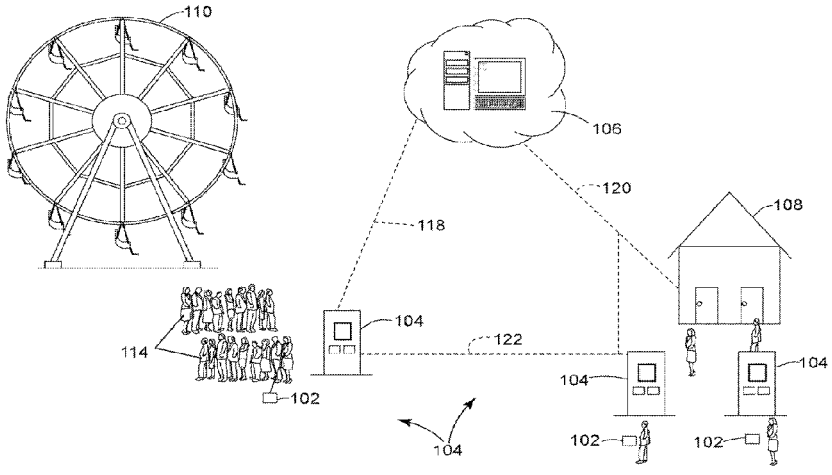
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Fig. 1



(57) Abstract: The present disclosure describes a method for managing theme park ride lines by providing an identifying device to a guest, the device configured to uniquely identify the guest, using the identifying device to ascertain an amount of time a guest spends at a predetermined location and reducing the amount of time a guest spends in a line queue for a predetermined ride by the amount of time the guest spends at the predetermined location. A system for managing theme park ride lines is also provided.

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